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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/657,530	09/08/2003	Leland S. Swanson	TI-33235.1	9171
	590 05/24/2004		EXAMINER ANYA, IGWE U	
TEXAS INST	RUMENTS INCORPO)RATED		
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DALLAS, TX	/5265	* _	ART UNIT	PAPER NUMBER
,•	•		2825	
			DATE MAILED: 05/24/2004	v , e

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)				
	Office Action Summary	10/657,530	SWANSON ET AL.				
	Sween Gummary	Examiner	Art Unit				
-	The MAILING DATE Full	lgwe U. Anya	2825				
	The MAILING DATE of this communication apperent	ears on the cover sheet with the c	orrespondence address				
	A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any						
	Status						
	1) Responsive to communication(s) filed on <u>08 Sep</u>	otombor 2000					
	2a) ☐ This action is FINAL . 2b) ☑ This action is non-final.						
1		e except for formal matters					
	3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
1	Disposition of Claims	Parto Quayio, 1999 C.D. 11, 493	3 O.G. 213				
1.	4) Claim(s) 33-39 is/are pending in the application.						
	4a) Of the above claim(s) is/are withdrawn						
	5) Claim(s)is/are allowed.	from consideration.					
	6) Claim(s) 33-39 is/are rejected.						
	7) Claim(s) is/are objected to.						
	8) Claim(s) are subject to rootriction and //						
8) Claim(s) are subject to restriction and/or election requirement.							
1	Application Papers						
1	9) The specification is objected to by the Examiner.						
	10) The drawing(s) filed on <u>08 September 2003</u> is/are. Applicant may not request that any objection to the	. a)⊠					
	Applicant may not request that any objection to the de-	a) accepted or b) objected	to by the Examiner.				
1	Applicant may not request that any objection to the dra	wing(s) be held in abeyance. See 3	7 CFR 1.85(a).				
1	Replacement drawing sheet(s) including the correction 11) The oath or declaration is objected to by the Example.	is required if the drawing(s) is object	ted to. See 37 CFR 1.121(d).				
1	to by the Exam	iner. Note the attached Office Ac	ction or form PTO-152.				
P	riority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).							
	a) ☐ All b) ☐ Some * c) ☐ None of:	only under 35 U.S.C. § 119(a)-(d) or (f).				
1	1. Certified copies of the priority documents ha	wo be to see					
1	2. Certified copies of the priority documents ha	ive been received.					
	2. Certified copies of the priority documents ha	ve been received in Application.	No				
	3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).						
	* See the attached detailed Office action to a track	C1 Rule 17.2(a)).					
	* See the attached detailed Office action for a list of the	e certified copies not received.					
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Att	achment(s)						
1) Notice of References Cited (PTO 802)							
2) Notice of Draftsperson's Patent Drawing Review (PTO 049)							
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date S) Notice of Informal Patent Application (PTO-152)							
S P	oftent and Trademark Office	6) Other:					
TOL	-326 (Rev. 1-04)						

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DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b); by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 2. Claims 33, 34 and 37 are rejected under 35 U.S.C. 102(e) as being anticipated by Schuegraf (US Patent 6620732).
- 3. Schuegraf teaches a bipolar transistor, comprising a collector region (402), a base region (420) overlying the collector region, an emitter-base dielectric stack comprising a carbide layer (444) sandwiched between oxide layers (442, 446) and having an opening exposing the base region (figs. 3A), and an emitter poly layer (430, 330) overlying the emitter-base dielectric and an exposed portion of the dielectric. The first oxide contacting the base comprises silicon oxide, the carbide layer comprises silicon carbide (col. 5 lines 52 67), and the second oxide comprises a silicon oxy nitride (col. 6 lines 12 31).

Claim Rejections - 35 USC § 103

4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

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(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

- 5. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).
- 6. Claims 35, 36, 38 and 39 are rejected under 35 U.S.C. 103(a) as being unpatentable over Schuegraf (US Patent 6620732) in view of Schuegraf (US Patent 6444535).
- 7. Schuegraf '732 teaches the features previously outlined, but lacks the thickness of the first oxide ranging from 70 100 angstroms, the first silicon oxide being a composite of a thermal silicon oxide 20 50 angstroms thick and a deposited silicon oxide of about 50 angstroms thereover, the silicon having a thickness of about 100 angstroms, and the second oxide layer being silicon oxide of thickness 500 1000 angstroms.
- 8. However, Schuegraf '535 teaches a first silicon oxide of thickness 80 500 angstroms (col. 5 lines 47 57), and a silicon carbide of thickness 500 1000 angstroms (col. 5 line 58 col. 6 line 2) for proper control of the emitter width.

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- 9. Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to combine the teachings of the Schuegraf references for proper control of critical dimension. Where the general conditions of a claim are disclosed in prior art discovering the optimum or working ranges involves only routine skill in the art. In re Aller, 105 USPQ 233.
- 10. Schuegraf '732 further teaches the invention can be practiced without the second oxide layer (col. 10 lines 32 39). Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to select a known oxide material on the basis of its suitability for second oxide layer. Provision for adjustability where needed involves only routine skill in the art. In re Stevens, 101 USPQ 284 (CCPA 1954).
- Any inquiry concerning this communication or earlier communications from the examiner should be directed to Igwe U. Anya whose telephone number is (571) 272-1887. The examiner can normally be reached on M F 8:30am 5:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew S. Smith can be reached on (571) 272-1907. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Igwe U. Anya Examiner Art Unit 2825

IA

May 3, 2004

MATTHEW SMITH SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 2800